Notice of Allowability	Application No.	Applicant(s)	
	09/536,037	LI ET AL.	
	Examiner	Art Unit	
	Toniae M. Thomas	2822	
The MAILING DATE of this communication apportunity All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in) or other appropriate communication is supplication is supplication in supplication i	this application. If not includation will be mailed in due	ded course THIS
1. This communication is responsive to the RCE filed on 11!	May 2005.		
2. ☑ The allowed claim(s) is/are <u>52-64</u> .			
3. \boxtimes The drawings filed on <u>27 March 2000</u> are accepted by the	Examiner.		
4. Acknowledgment is made of a claim for foreign priority unall All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority do International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submin INFORMAL PATENT APPLICATION (PTO-152) which give 6. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in til. 7. DEPOSIT OF and/or INFORMATION about the deposattached Examiner's comment regarding REQUIREMENT in the content of the comment of the comment of the deposattached Examiner's comment regarding REQUIREMENT in the comment of	e been received. e been received in Application cuments have been received of this communication to file a lENT of this application. itted. Note the attached EXAMES reason(s) why the oath or contact be submitted. on's Patent Drawing Review of Amendment / Comment or in the header according to 37 CFR sit of BIOLOGICAL MATER	No in this national stage applicate the reply complying with the reply complying with the reply complying with the replacement of the Office action of the Complete the control of	quirements
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 05/11/05; 10/03/05 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Sun Paper No./M 8), 7. ☐ Examiner's Al	ail Date mendment/Comment atement of Reasons for Allo	wance
		Mary Wilcze Primary Exa	miner Miner

EXAMINER'S AMENDMENT

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Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after allowance or after an Office action under *Ex Parte Quayle*, 25 USPQ 74, 453 O.G. 213 (Comm'r Pat. 1935). Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, prosecution in this application has been reopened pursuant to 37 CFR 1.114. Applicant's submissions filed on 11 May 2005 and 03 October 2005 have been entered.

Reasons for Allowance

2. The following is an examiner's statement of reasons for allowance: the newly submitted and newly cited prior art of record does not anticipate, teach, or suggest a method for forming a low k inter-level dielectric layer substantially as claimed, wherein the method comprises forming a dielectric layer comprising a compound of silicon bonded to both nitrogen and an organic material, and subsequently exposing the dielectric layer to a plasma comprising nitrogen – the nitrogen-comprising plasma effective to reduce the dielectric constant to below what it was prior to the step of exposing.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should

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preferably accompany the issue fee. Such submissions should be clearly

labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Toniae M. Thomas whose telephone number is (571) 272-1846. The examiner can normally be reached on Monday through Friday from 8:30 a.m. to 5:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra Smith can be reached on (571) 272-2429. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TMT

11 December 2005

Mary Wilczewski Primary Examiner

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